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Customer Number



Patent  
Case No.: 59555US002

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

First Named Inventor: MAO, GUOPING  
Application No.: 10/784398 Group Art Unit: 1775  
Filed: February 23, 2004 Examiner: Unknown  
Title: ETCHED POLYCARBONATE FILMS

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

CERTIFICATE OF MAILING	
I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on:	
7-28-04	<i>Melanie Gover</i>
Date	Signed by: Melanie G. Gover

Dear Sir:

Pursuant to 37 CFR §§ 1.56, 1.97, and 1.98, enclosed is a completed Form PTO-1449, citing references submitted for consideration by the Examiner. Copies of any cited foreign patents, non-patent literature, and unpublished US application documents are enclosed. Pursuant to the waiver in the Pre-OG Notice, dated July 11, 2003, copies of US patents and published US patent applications are no longer required and are not enclosed. It is respectfully requested that the Examiner initial and return the enclosed Form PTO-1449 to indicate that each reference has been considered.

It is believed that no fee is due; however, in the event a fee is required, please charge the fee to Deposit Account No. 13-3723.

Respectfully submitted,

July 28, 2004  
Date

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# INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use as many sheets as necessary)

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Art Unit	1775
Examiner Name	Unknown
Attorney Case Number	59555US002

## U.S. Patent Documents

Exam. Init.*	Cite No.	Document Number	Publication Date or Issue Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Doc. Number-(Kind Code if Known)			
	A1	US- 3,448,098	06-03-1969	Gaines et al.	
	A2	US- 3,469,982	09-30-1969	Celeste	
	A3	US- 3,526,504	09-01-1970	Celeste	
	A4	US- 3,867,153	02-18-1975	MacLachlan	
	A5	US- 5,227,008	07-13-1993	Klun et al.	
	A6	US- 6,218,022 B1	04-17-2001	Suzuki et al.	
	A7	US- 6,403,211 B1	06-11-2002	Yang et al.	
	A8	US- 2002/0028293 A1	03-07-2002	Yang et al.	
	A9	US- 2002/0155280 A1	10-24-2002	Yang	

## Foreign Patent Documents

Exam. Init.*	Cite No.	Foreign Patent Document		Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	Translation (Check if yes)
		Ctry. Code	Number-KindCode (If known)				
	B1	WO	02/100135 A2	12-12-2002			
	B2	WO	01/56771 A2	08-09-2001			
	B3						
	B4						
	B5						
	B6						
	B7						

## OTHER DOCUMENTS

Exam. Init.*	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	Translation (Check if yes)
	C1	KUMAMOTO, Y. "Measurement of Low Neutron Fluences With Polycarbonate Foils Electrochemically Etched with Methyl Alcohol-Koh Solution", <u>Health Physics</u> , Vol. 42, No. 4 (April) pp 497-502, 1982	
	C2	PARETZKE, H. G. et al, "The Etching of Polycarbonate Charged Particle Detectors By Aqueous Sodium Hydroxide", <u>Nuclear Instruments and Methods</u> 107 (1973) pp. 597-600	
	C3	"Enhancement of Track Etching Rates in Charged Particle-irradiated Plastics by a Photo-oxidation Effect", <u>Nature</u> , Vol. 220, December 28, 1968, pp. 1313-1314	

\*Examiner:

Date Considered:

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Information Disclosure Statement)